

Attorney Docket: 29936/39481

Inventor: Ihl Hyun Cho

Title: "Method of Manufacturing Semiconductor
Devices"

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FIG. 1

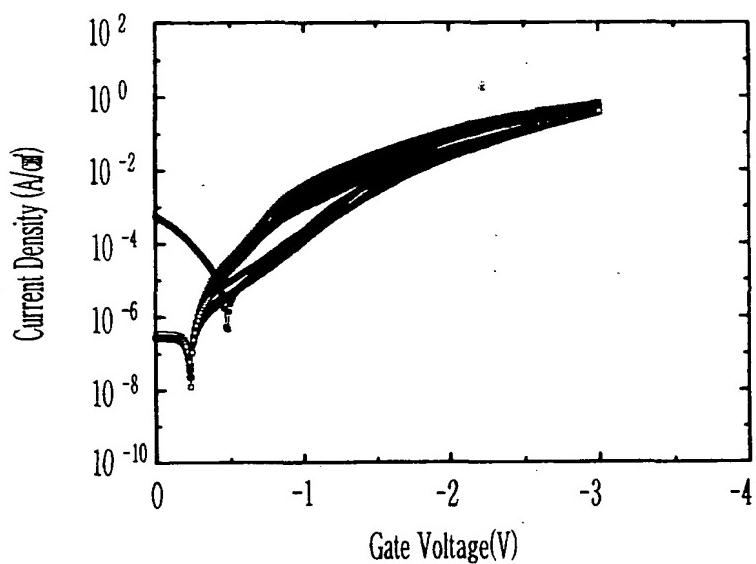
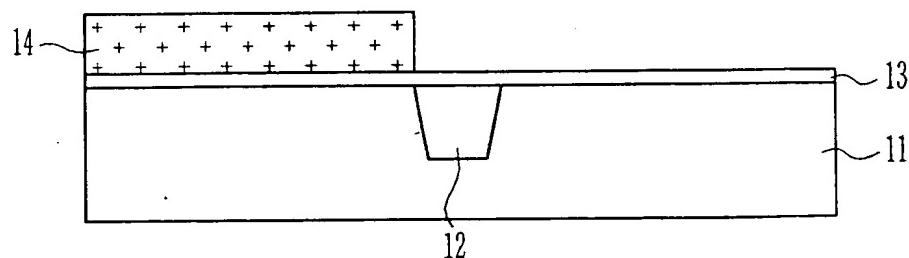


FIG. 2A



Removal of Photoresist Film using Solvent

FIG. 2B

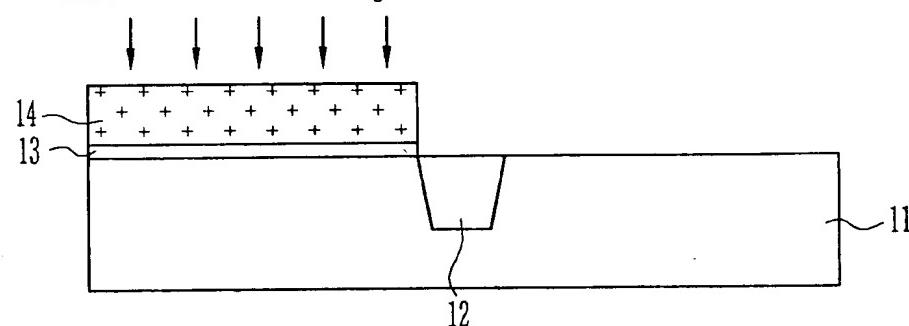


FIG. 2C

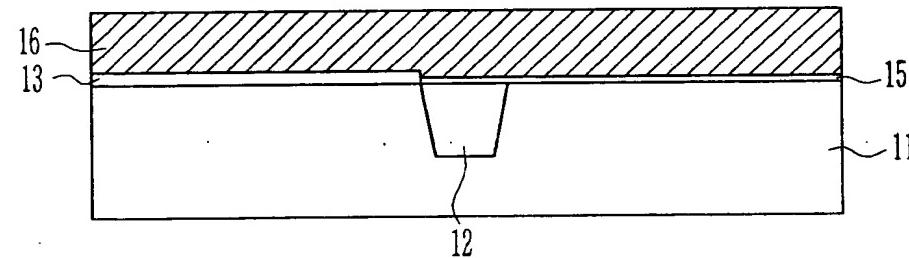
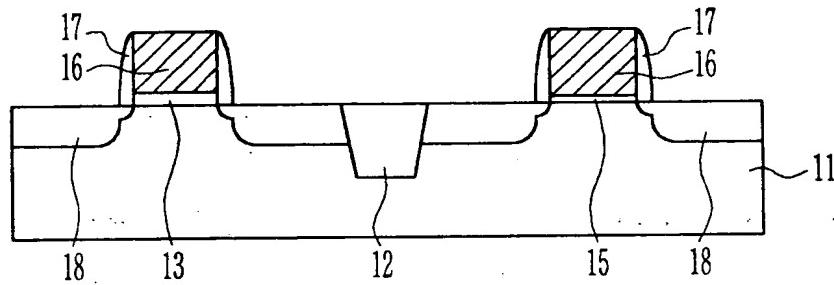


FIG. 2D



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FIG. 3

